

High-Purity Chemicals in Electronic Applications

Training guide for filtration products





ENGINEERING YOUR SUCCESS.

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For technical or application support related to our fluid filtration solutions, please call our toll free number **877 784 2234** or email **bioscience.na@parker.com**

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Parker has a continuous policy of product development and although the Company reserves the right to change specification, it attempts to keep customers informed of any alterations. This publication is for general information only and customers are requested to contact our Process Filtration Sales Department for detailed information and advice on a product's suitability for specific applications. All products are sold subject to the company's Standard conditions of sale. Schematic

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High-Purity Solvents Isopropyl Alcohol (IPA)

High-Purity Acids & Bases Hydrofluoric Acid

High-Purity Acids & Bases Sulfuric Acid

High-Purity Acids & Bases Hydrogen Peroxide

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Introduction

Providing a cost-effective filtration technology that ensures consistent quality and process optimization

High-purity chemicals and materials are essential in manufacturing microelectronics devices that are enabling advances in work, life science, communications, transportation, efficient lighting, entertainment, shopping, and many other areas that affect our lives.

Parker's proven product range and applications experience in the manufacturing of these high-purity chemicals, chemistries, and solvents allows our customers to meet the high-purity requirements that enable constant technical advancement of their customers. While each application is unique, we can often divide high-purity applications into the following broad processes:

- Ultra-pure water is needed to enable production of liquid high-purity chemical, or to dilute concentrated chemical into the concentration required by the customer.
- Specialty chemical-vapor filtration which is unique to polysilicon production.
- Distillation in some processes may be done in a very aggressive, high-temperature environment requiring a special filtration solution.
- Venting of tanks with hydrophobic filters to relieve gas pressure build-up.
- Anhydrous and other industrial liquid raw materials may require filtration from tankers, pipelines, or other large vessels before they are introduced to the high-purity manufacturing system.
- Pre-filtration or clarification through the manufacturing process is typical and necessary to guarantee quality specifications throughout the process.
- Final package filtration is the last particle barrier and the final critical filtration step in the high-purity manufacturing process.

Given the variations of these processes for high-purity chemicals, chemistries, and solvents, it is critical to consider the operating parameters when selecting filtration for each stage of manufacturing.

As our customers require fewer and smaller particles and the need for lower metal extractables increases, it is essential for us to fully understand their applications and process demands. In addition to helping our customers achieve their final specification, we must recommend filtration solutions that minimize process downtime and reduce product waste. The total cost of ownership must be considered without compromising the quality of the end product.

Market Applications

- High-purity concentrated acids
- High-purity acid blends
- High-purity bases
- High-purity alkaline solutions
- High-purity solvents
- Some photoresists and polyimides
- Anti-reflective coatings
- Developers negative and positive
- Organic solvents used to strip photoresist polymer
- CMP base chemicals acids or bases
- High-purity plating solutions
- Trichlorosilane vapor and liquid



Introduction

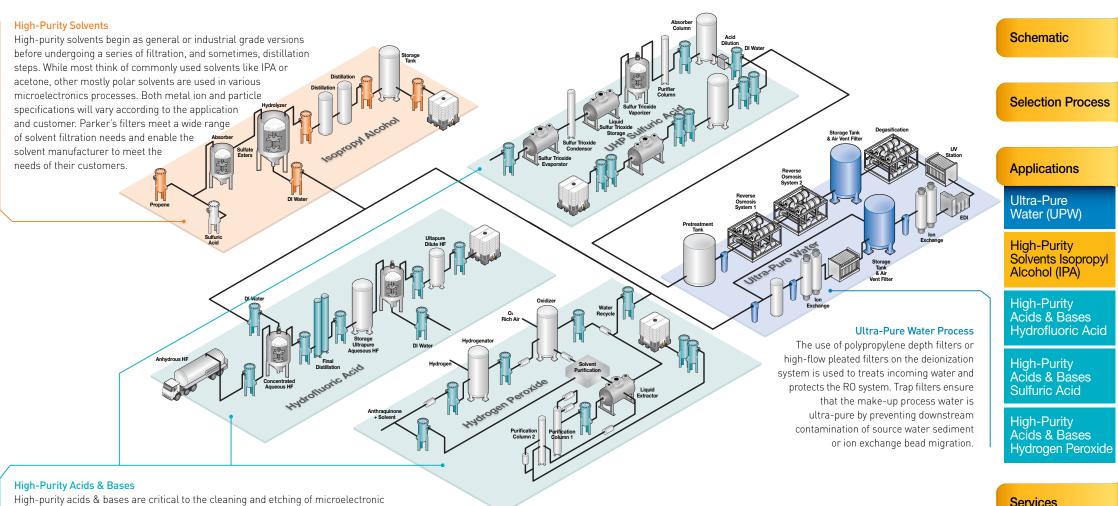
High-Purity Acids & Bases Hydrogen Peroxide

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High-Purity Chemical Application Overview



devices, especially semiconductors. Parker's lineup of filters are well suited for achieving the challenging particle and ionic specifications the chemical companies need to meet. Filtration is progressive, getting tighter throughout the process. Materials of construction must not only be highly compatible and provide good performance, but must also offer outstanding value. While polypropylene may be compatible in a particular acid or base for one manufacturer, it may not be suitable for another whose end user customers require ultra low metal extractables. Parker can meet the needs of both customers.

For detailed products in each process application, see pages 5 - 9.

Selection Matrix

Introduction

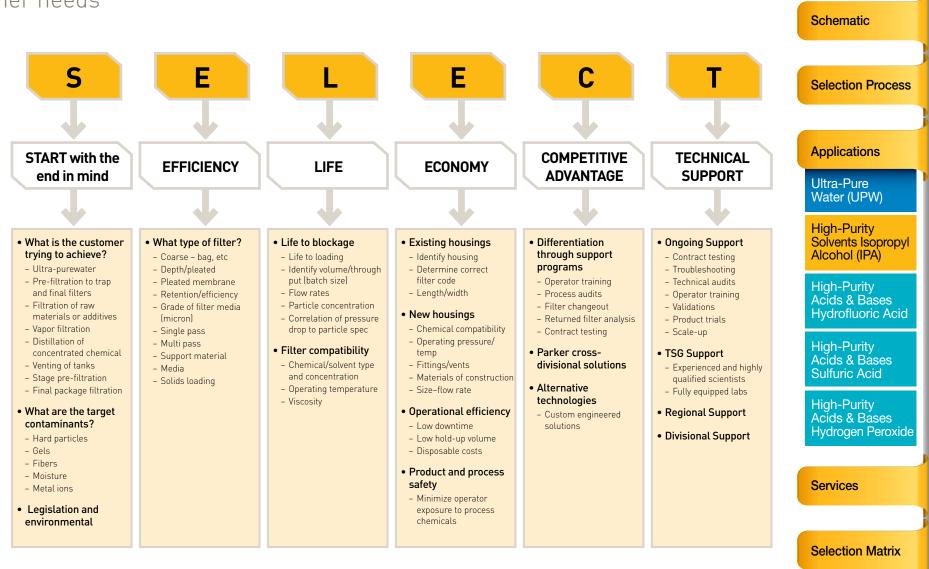
Selection Process

Identifying customer needs

In order to meet filtration specifications, physical and chemical conditions of the process have to be considered.

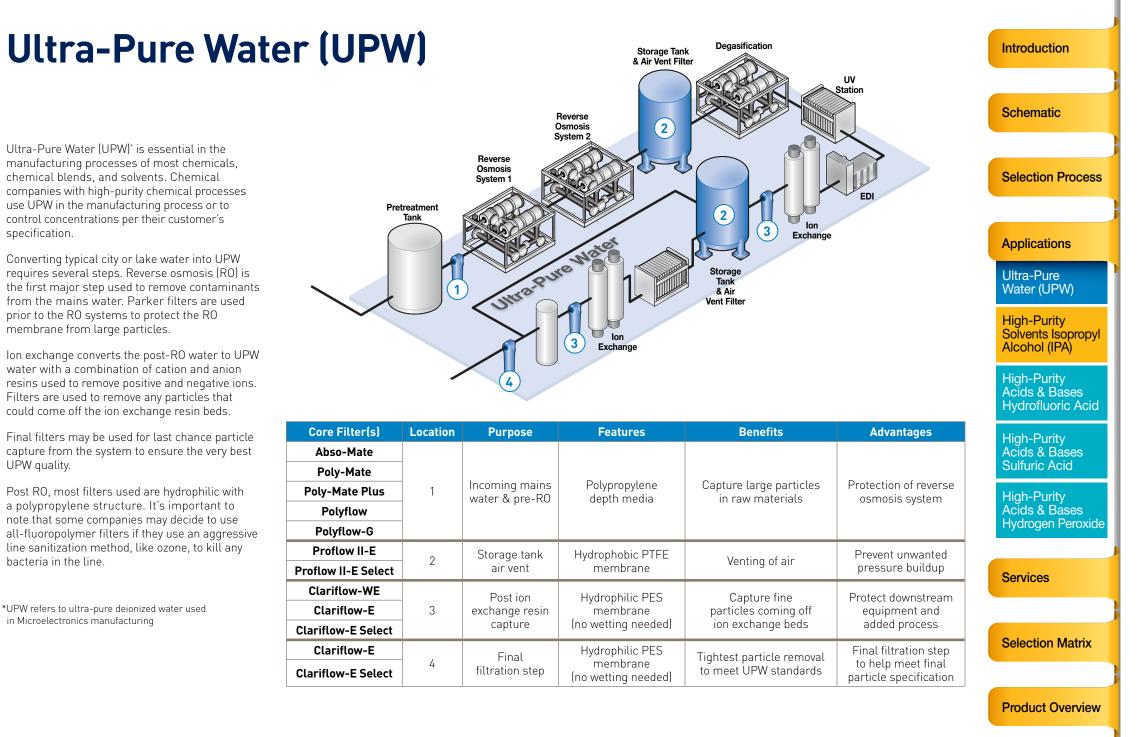
It is therefore essential that a methodical process for identifying the customer's needs is followed.

The SELECT process builds on principles used to select the optimized filtration solution for the high-purity chemical manufacturer.



Product Overview

Introduction



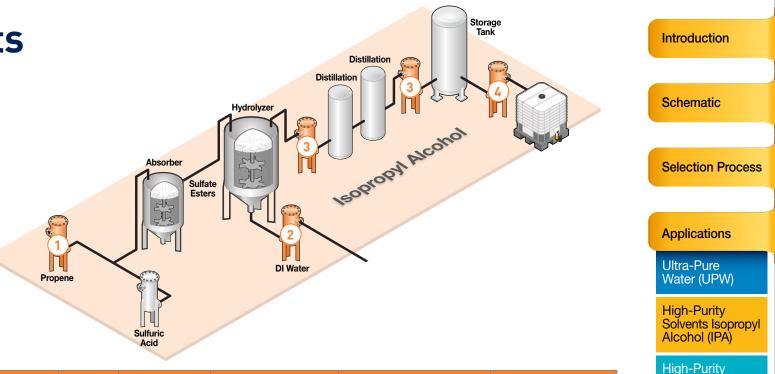
High-Purity Solvents Isopropyl Alcohol (IPA)

Isopropyl Alcohol (IPA) is the most common solvent used in semiconductor manufacturing. It may be used to rinse wafers in certain processes where water contact is not desirable. IPA is also used to dry wafers and other Microelectronics devices since it will not streak or leave watermarks. While there are different methods of manufacturing IPA, a common one is through the combination of propene and sulfuric acid to create sulfate esters. Parker melt blown and pleated depth filters may be used to filter these raw materials.

The hydrolization process combines the sulfate esters and Ultra-Pure Water (UPW). A hydrophilic filter may be used to filter incoming UPW. As the newly created IPA leaves the hydrolyzer, it may pass through filtration prior to other process steps including distillation.

The number of distillation steps will depend on the level of purity required. Though not shown here, some manufacturers may use filters during or between distillation steps. Following distillation, a series of filtration steps may be used to further reduce inline particle size and quantity.

Final package filtration is a last chance particle removal step. This is typically where inline particle counters will be used to monitor particle size and quantity. Here, filters will be tighter than upstream filters in the manufacturing process. Micron rating will depend on the end user particle specification.



| Core Filter(s) | Location | Purpose | Features | Benefits | Advantages | Acids & E | |
|---------------------|----------|---------------------------|---|---|----------------------------------|---|--|
| Abso-Mate | | Incoming raw materials | Polypropylene depth media | Capture large particles in raw materials | | Hydrofluo | |
| Poly-Mate | | | | | Protection of absorption process | High-Pur | |
| Poly-Mate Plus | 1 | | | | | Acids & E | |
| Polyflow | | | | | | Sulfuric A | |
| Polyflow-G | | | | | | High-Pur | |
| Clariflow-WE | | | | | Provide consistent | Acids & E | |
| Clariflow-E | 2 | DI water | _ Hydrophilic PES membrane | Removal of particles in UPW down to 0.02 microns | source of UPW to | Hydrodon | |
| Clariflow-E Select | | | Inembidite | | hydrolyzer | | |
| Chemflow-PE | 3 | | | | | Services | |
| Chemflow-PE Select | | Pre and post | either HDPE or PP Fine particle removal distillat | | Protect and enhance | Services | |
| Proflow II-E | | distillation | | support structure | distillation pro | distillation process | Fine particle removal distillation process |
| Proflow II-E Select | | | | | | | |
| Chemflow-PE | | | | | | Selection | |
| Chemflow-PE Select | - 4 | | <u> </u> | PTFE membrane on | | Final filtration step to help meet final | |
| Proflow II-E | | 4 Final package | either HDPE or PP support structure | Fine particle removal | product particle | | |
| Proflow II-E Select | | | | | specification | Product (| |

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Acid

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Bases

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n Peroxide

High-Purity Acids & Bases Hydrofluoric Acid

High-purity hydrofluoric (HF) acid begins with the mixing and chemical interaction of sulfuric acid and dry fluorspar (CF2). The result of mixing those in a rotary kiln is HF gas. The HF gas is condensed then distilled to form anhydrous hydrofluoric acid.

In this diagram, the industrial anhydrous HF is delivered via tanker or pipeline to become ultra-pure HF commonly used in semiconductor wafer etch and clean processes. Parker membrane filters with either HDPE or PFA structures may be used throughout the manufacturing process.

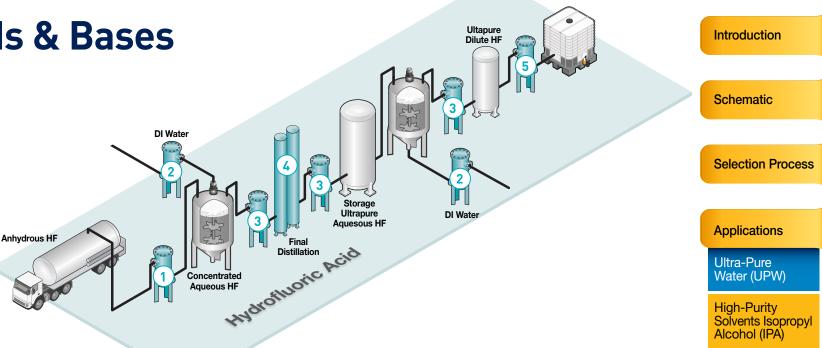
Distillation is an important step in producing ultra-pure hydrofluoric acid. The aggressive nature of the acid combined with temperatures high enough to vaporize the HF make this a challenging filter application. For that reason. only 100% fluoropolymer filters can be used.

The HF vapor can pass through the PTFE membrane, then re-condense in to a purer form with ultra low contaminants. As the ultra-pure concentrated HF exits the distillation process, a filtration step to remove additional particles may be present.

From here, the ultra-pure concentrated HF may be blended with ultra-pure water to various desired concentrations.

Parker filters ensure process consistency and enable the HF manufacturer to meet the final particle specification for their end user customers.

It's important to note that while polypropylene filters, like Parker's Proflow-II-E, could be used in dilute HF, both HDPE and PFA are considered to be more chemically robust and would typically be recommended.



| Core Filter(s) | Location | Purpose | Features | Benefits | Advantages | High-Purity | |
|--------------------|----------|---------------------------------------|---|---|---|------------------------------------|------------------|
| Chemflow-PE | _ | Optional Incoming raw materials | PTFE membrane on either HDPE or PFA support structure | More open ratings to capture large particles in raw materials | Process particle control | Acids & Bases Hydrofluoric Acid | |
| Chemflow-PE Select | | | | | | | |
| Fluoroflow | | | | | | High-Purity | |
| Fluoroflow-HSA | | | | | | Acids & Bases Sulfuric Acid | |
| Clariflow-WE | | | | | Provide consistent | | |
| Clariflow-E | 2 | DI water | Hydrophilic PES membrane | Removal of particles in UPW down to 0.02 microns | course of DIW to | High-Purity | |
| Clariflow-E Select | | | membrane | | | Acids & Bases Hydrogen Peroxide | |
| Chemflow-PE | | | | Fig. a sticle service | Process particle | | |
| Chemflow-PE Select | 3 | Stage/ | PTFE membrane on | | | | |
| Fluoroflow | - 3 | 3 | 3 pre-filtration/ blending | either HDPE or PFA support structure | Fine particle removal | control | Services |
| Fluoroflow-HSA | | | | | | | |
| Fluoroflow | - 4 | High temp acid | 100% fluoropolymer | Temperature rating | Coalesce water and | | |
| Fluoroflow-HSA | | dis | distillation | construction | up to 180C | particle removal | Selection Matrix |
| Chemflow-PE | - 5 | 5 Fine particle removal | e PTFE membrane on either HDPE or PP support | Fine particle removal | Final filtration step to help meet final | | |
| Chemflow-PE Select | | | | | | | |
| Fluoroflow | | | | | | Developed Operations | |
| Fluoroflow-HSA | | | | | | Product Overview | |

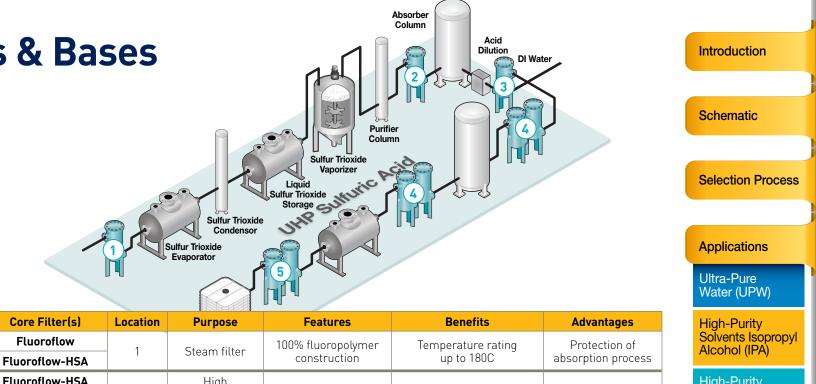
High-Purity Acids & Bases Sulfuric Acid

Sulfuric acid is highly used with either hydrogen peroxide or ozonated UPW to create an intended exothermic reaction. The added energy to this aggressive acid is ideal for removing hard-baked photoresists and most organic contaminants from the surface of silicon production wafers.

A common method of creating sulfuric acid begins by mixing oleum and steam to produce sulfur trioxide vapor. Filters may be used to remove large particles and provide protection to the evaporator.

The SO3 is condensed then vaporized again just before entering a series of purifier columns. The number of purifiers will depend on the H2SO4 specification. Exiting the absorber column is pure concentrated sulfuric acid.

The pure concentrated acid is cooled and carefully diluted into usable concentrations. From there, the acid goes through a series of membrane filtration steps, each succeeding step tighter than the previous until particle specifications are met and the product is packaged for the end user.



| Fluoroflow-HSA | | | Construction | up to 1800 | absorption process | |
|---|---|---|---|---|--|---|
| Fluoroflow-HSA Fluoroflow-Select Fluoroflow-XL | 2 | High temperature acid vaporization | 100% fluoropolymer construction | Temperature rating up to 180C | Protect and enhance distillation process | High-Purity Acids & Bases Hydrofluoric Acid |
| Clariflow-WE Clariflow-E Clariflow-E Select | 3 | DI water | Hydrophilic PES membrane | Removal of particles in UPW down to 0.02 microns | Provide consistent source of UPW | High-Purity Acids & Bases Sulfuric Acid |
| Chemflow-PE Chemflow-PE Select Proflow II-E Proflow II-E Select Fluoroflow-HSA Fluoroflow-Select | 4 | Stage/ pre-filtration/ blending | PTFE membrane on either HDPE,PFA or PP support structure | Fine particle removal | Process particle control | High-Purity Acids & Bases Hydrogen Peroxide Services |
| Chemflow-PE Chemflow-PE Select Proflow II-E Proflow II-E Select Fluoroflow-HSA Fluoroflow-Select | 5 | Final package | PTFE membrane on either HDPE, PFA or PP support structure | Fine particle removal | Final filtration step to help meet final product particle specification | Selection Matrix Product Overview |

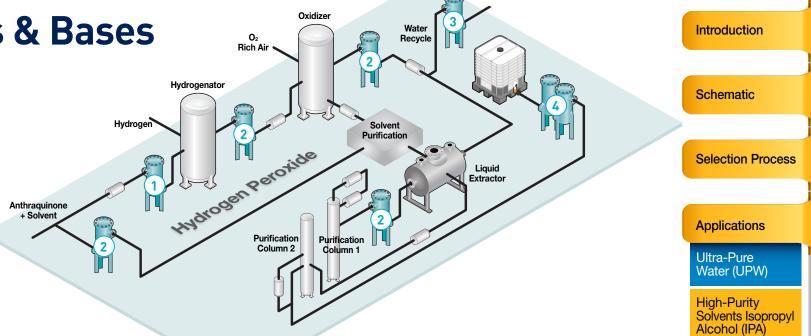
High-Purity Acids & Bases Hydrogen Peroxide

Hydrogen peroxide is made in a series of steps. A hydrocarbon-based "work-solution" is fed to the hydrogenator along with a stream of hydrogen where hydrogenation occurs over a bed of Ni or Pd catalysts.

The first filtration step is used to capture catalyst particles from the hydrogenated fluid.

In the oxidizer, oxygen-rich air is introduced to the work solution to reverse the previous reaction. The resulting work-solution contains about 40% H_2O_2 by weight as it goes into the liquid extractor. Water is fed into the extractor and since the H_2O_2 is miscible in water while the solvent is not, the water-peroxide layer can be removed and sent to the purification columns.

In the purification columns, the water-peroxide mixture is further concentrated and purified. For UHP hydrogen peroxide, multiple columns may be used.



| Core Filter(s) | Location | Purpose | Features | Benefits | Advantages | High-Purity |
|---------------------|----------|---------------------------------------|---|---|---|-------------------|
| Abso-Mate | _ | Incoming raw materials | Polypropylene depth media | Capture large particles in raw materials | Protection of evaporator | Acids & Bases |
| Poly-Mate | | | | | | Hydrofluoric Acid |
| Poly-Mate Plus | 1 | | | | | High-Purity |
| Polyflow | | | | | | Acids & Bases |
| Polyflow-G | | | | | | Sulfuric Acid |
| Chemflow-PE | | | | | | High-Purity |
| Chemflow-PE Select | 2 | Stage/ pre-filtration/ blending | PTFE membrane on either HDPE or PP support structure | Fine particle removal | Process particle control | Acids & Bases |
| Proflow II-E | | | | | | Hydrogen Peroxide |
| Proflow II-E Select | | | | | | |
| Clariflow-WE | | DI water | Hydrophilic PES membrane | | Provide consistent source of UPW to liquid reactor | Services |
| Clariflow-E | 3 | | | | | |
| Clariflow-E Select | | | membrane | | | |
| Chemflow-PE | | | PTFE membrane on either HDPE, PP or PFA support structure | Fine particle removal | Final filtration step to help meet product specifications | Selection Matrix |
| Chemflow-PE Select | 4 | Final Package | | | | Selection Matrix |
| Proflow II-E | | | | | | |
| Proflow II-E Select | | | | | | |
| Fluoroflow | | | | | | Product Overview |

Services Technical Support Group (TSG)

In these industries, manufacturers and end-users face stringent environmental and operational compliances, where the trend is to ensure low Volatile Organic Compounds (VOC) exposure and spillage of hazardous waste while providing a more user friendly process environment. Combined with the market demands for high quality products, this means that the raw materials and chemistries used in formulations result in higher manufacturing costs.

Parker is committed to providing comprehensive technical support of our products through our global sales network and dedicated technical support group. Our team of trained scientists, engineers and technicians is available to answer questions on the capabilities of our products, assist customers to select, specify and design filtration systems to meet specific user requirements, and provide a range of advisory and troubleshooting services.

We provide technical support to assist in training operators on a wide range of activities related to using our products, system sizing and performance optimization.

Results can be utilized to manipulate pre and final filter trains to achieve the desired throughput and quality without over processing.

Services Overview

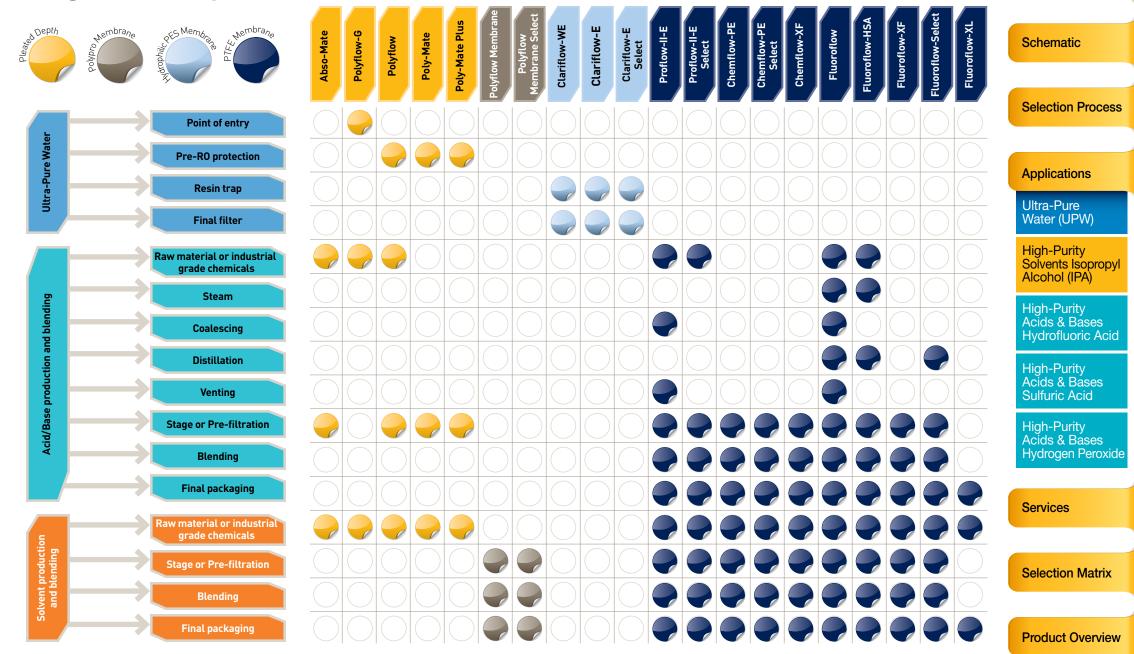


Product Overview

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High-Purity Chemicals Selection Matrix



Introduction

PTFE Membrane Filter Cartridges

Chemflow[®]-PF

- Good flow rates
- Good lifetime
- Wet-pack option for quick installation PTFE/HDPE construction for chemical resistance
- 100% integrity tested in cleanroom environment

Chemflow-PE provides a low metals, economical alternative to all-fluoropolymer cartridges. Ideally suited for final packaging of high-purity chemicals and solvents and most lower temperature chemical delivery and wet process (<60°C) applications.



- Chemflow[®]-PF Select
- High flow rates
- Long lifetime
- Wet-pack option for quick installation
- PTFE/HDPE construction for chemical resistance
- 100% integrity tested in cleanroom environment

The addition of the SELECT pleat technology provides a high-flow, low metals, and economical alternative to all-fluoropolymer high surface area cartridges. Ideally suited for final packaging of high-purity chemicals and solvents and many low temperature chemical delivery and wet process (<60°C) applications.



Chemflow[®]-XF

- Highest flow rates in the industry for a 2.75" wide cartridge Long lifetime
- Wet-pack option for quick installation
- PTFE/HDPE construction for chemical resistance
- 100% integrity tested in cleanroom environment

The asymmetric PTFE membrane provides unmatched flow rates and on-stream life to help improve throughput and reduce filtration costs. Ideally suited for final packaging of high-purity chemicals and solvents and many low temperature chemical delivery and wet process (<60°C) applications.

Fluoroflow®

- · Economical all-fluoropolymer cartridge
- High particle retention
- Wet-pack option for guick installation
- All-fluoropolymer for maximum chemical resistance
- 100% integrity tested in cleanroom environment

Fluoroflow is an economical all-fluoropolymer solution for low to medium flow high purity chemical applications that require the highest chemical resistance. This filter is ideally suited for nearly all high-purity chemical and solvent manufacturing applications including those requiring a high temperature rating (150°C).

Fluoroflow[®]-XF

- Highest flow rates in the industry for a 2.75" wide cartridge
- High flux asymmetric PTFE membrane rates for increased flow
- Wet-pack option for quick installation
- All-fluoropolymer for maximum chemical resistance
- 100% integrity tested in cleanroom environment

This cartridge provides excellent flow and chemical resistance for the most aggressive applications up to 150 °C. Fluoroflow-XF is ideally suited for high-purity chemical manufacturing processes and recirculated clean, etch, or plating applications where particle removal efficiency is improved with high bath turnover.

Proflow[™] II-F

- · Economical, high-purity chemical and solvent filtration
- Good liquid and gas flow rates
- · Wet-pack option for guick installation
- PTFE/ PP construction for high chemical resistance
- 100% integrity tested in cleanroom environment

Proflow-II-E uses a PTFE membrane with high purity polypropylene supports to provide an economical yet high-purity filtration solution for high-purity chemical, solvent and gas applications. This filter is ideal for many high-purity chemical and solvent manufacturing applications.

Fluoroflow[®]-HSA

Increased filtration area for longer life

- High particle retention
- Wet-pack option for guick installation
- All-fluoropolymer for most maximum chemical resistance
- 100% integrity tested in cleanroom environment

• Extra-high filtration area in a 3.25" wide cartridge

Highest flow rates for maximum bath turn over

100% integrity tested in cleanroom environment

Wet-pack option for guick installation

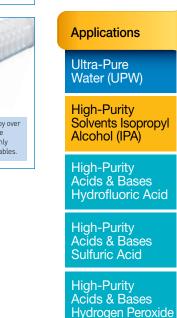
Ultraclean option for absolute cleanliness

This cartridge is a high surface area all-fluoropolymer solution for medium flow high purity chemical applications that require the highest chemical resistance and desire longer life. This filter is ideally suited for nearly all high-purity chemical and solvent manufacturing applications including those requiring a high temperature rating (150°C).

Fluoroflow[®] Select

- Highest filtration area in a 2.75" width cartridge
- High flow rates for increased bath turn over
- Wet-pack option for guick installation
- All-fluoropolymer for maximum chemical resistance
- 100% integrity tested in cleanroom environment

The addition of the SELECT pleat technology increases filtration area and flow rate by over 70% versus our standard Fluoroflow to achieve the highest flow and longest filter life available in a 2.75" width cartridge. The all-fluoropolymer construction provides highly efficient particle removal, excellent chemical resistance, and very low metal extractables.



Introduction

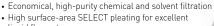
Schematic

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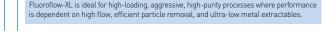
- 100% integrity tested in cleanroom environment
- An economical, yet high-performance filter cartridge for high-purity chemical and solvent applications, the Proflow II-E Select uses a PTFE membrane along with polypropylene supports. With SELECT pleating, liquid flow rates are increased by up to 50% verses our standard Proflow II-E.

Uses a larger diameter cartridge (3.25") combined with our unique SELECT pleating

technology to achieve our highest surface area, highest-flow all-fluoropolymer filter.

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Fluoroflow[®]-XI

Proflow[™] II-F Select

- liquid flow rates
- Wet-pack option for quick installation
- PTFE/ PP construction for chemical resistance

Pleated Depth Filter Cartridges

Abso-Mate®

- · Non-fiber releasing and low extractables
- Single-piece construction eliminates bypass concerns
- All-polypropylene construction offers wide chemical compatibility with most chemicals
- Absolute rated for consistent and reliable performance [99,98%]

Cost-effective and absolute rated for capturing particles 0.2 to 70 µm in size. This pleated melt blown cartridge is of all-polypropylene construction, and without adhesives that could potentially contaminate fluids.

Fulflo[®] Poly-Mate[™]

- All Polypropylene construction maximizes chemical resistance
- Pleated surface area offers extended service life. low pressure drop and high flow capacity
- One-piece, continuous to 40 inches length, integrally sealed pleated filter media
- Non-fiber releasing polypropylene construction

A unique combination of polypropylene melt blown and spun-bonded pleated media provides retention ratings of 0.5 to 60 µm at 99% efficiency.

Polypropylene Membrane Filter Cartridges

Polyflow[®] Membrane

- Highly-retentive polypropylene membrane
- Wide range of configurations and ratings
- Wet-pack option for guick installation
- 100% thermally welded virgin polypropylene construction
- 100% integrity tested in cleanroom environment

This all-polypropylene filter cartridge is optimized for use in certain electronics applications such as the manufacturing of high-purity solvents and most G or I-line photoresists. Every cartridge is fabricated in a clean room environment, pre-flushed with 18 megohm-cm ultrapure DI water, and 100% integrity tested.

Hydrophilic PES Membrane Filter Cartridges

Clariflow[®]-F

- High-retention hydrophilic PES membrane
- Good flow rate DI water and dilute acids and bases.
- Rating down to 0.02 microns
- 100% integrity tested in cleanroom environment

Clariflow-E filter cartridges are optimized for semiconductor DI water and dilute aqueous-based chemicals. A mirrored-anisotropic hydrophilic PES (Polyethersulfone) membrane allows for quick and convenient startup without the need for pre-wetting.

Polyflow®

- High-retention depth matrix for economical prefiltration
- High flow rate and long service life reduce processing time
- Wide variety of configurations and ratings
- Broad chemical compatibility allows use in most applications Thermally bonded virgin polypropylene construction
- minimizes extractables

Thermally bonded, absolute rated 100% virgin polypropylene to provide absolute filtration cartridge features a random-fiber polypropylene depth matrix to provide excellent retention efficiencies. Ideally suited for most high-purity chemical and solvent pre-filtration applications.

Fulflo® Poly-Mate[™] Plus

- Fixed pore construction provides
- ultimate particle retention
- Offers high flow rates and extended service life
- Non-fiber releasing enabling consistent quality filtration performance
- One piece integral construction for maximum cartridge integrity

A unique combination of polypropylene melt blown and spun-bonded pleated media provides high surface area at retention ratings of 0.25 to 100 µm at 90% efficiency.

Polyflow[®] Membrane Select

- Highly-retentive polypropylene membrane
- Unique SELECT pleating technology for higher flow and longer life
- · Wet-pack option for guick installation
- 100% thermally welded virgin polypropylene construction
- 100% integrity tested in cleanroom environment

Polyflow-Membrane-Select is a higher surface area, all-polypropylene filter cartridge ideal for use in certain electronics applications such as the manufacturing of high-purity solvents and most G or I-line photo resists. Every cartridge is fabricated in a clean room environment. pre-flushed with 18 megohm-cm ultrapure DI water, and 100% integrity tested.



Polyflow[®]-G

- Depth matrix for economical prefiltration
- High flow rate and long service life reduce processing time
- Wide variety of configurations and ratings
- Broad chemical compatibility allows use in most applications Thermally bonded virgin polypropylene construction minimizes extractables

These nominal-rated depth filter cartridges are thermally bonded from 100% virgin polypropylene. Polyflow-G's high dirt-loading, random-fiber polypropylene depth media provides consistent particle retention and protection of upstream filters.

Applications

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Ultra-Pure Water (UPW)

High-Purity Solvents Isopropyl Alcohol (IPA)

Hiah-Purity Acids & Bases Hydrofluoric Acid

> High-Purity Acids & Bases Sulfuric Acid

High-Purity Acids & Bases Hydrogen Peroxide

Services

Selection Matrix

Product Overview



- High-retention hydrophilic PES membrane Unique SELECT pleating technology for high flow rate and increased life
- DI water and dilute acids and bases.
- Rating down to 0.02 microns
- 100% integrity tested in cleanroom environment

Clariflow-E-SELECT filter cartridges are optimized for high-flow microelectronics DI water and dilute aqueous-based chemical microelectronics applications. The SELECT pleated, mirrored-anisotropic hydrophilic PES (Polyethersulfone) membrane enables quick and convenient startup without the need for pre-wetting.

Clariflow[®]-WF

- Economical filtration High-retention hydrophilic PES membrane
- DI water and dilute acids and bases
- Rating down to 0.04 microns
- 100% integrity tested in cleanroom environment

Clariflow-WE filter cartridges are an economical option for filtering DI water filtration and other dilute aqueous solutions. The filter features a hydrophilic PES membrane and all polypropylene support structure for cost efficient and convenient filtration.

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